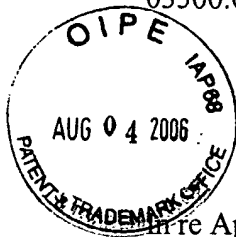


IFW

03500.017636.

PATENT APPLICATION



IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Re Application of:)
:)
SHUNICHI ISHIHARA, et al.)
: Group Art Unit: 2812
Application No.: 10/530,189)
:)
371(c) Date: February 3, 2006)
:)
Int'l Filing Date: October 10, 2003)
:)
For: POLYCRYSTALLINE SILICON)
SUBSTRATE : August 3, 2006

Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

REQUEST FOR CORRECTED FILING RECEIPT

Sir:


Applicants have received an official Filing Receipt in the above-identified application in which the title contains a typographical error. The title should read:

--POLYCRYSTALLINE SILICON SUBSTRATE--.

The requested correction is indicated on the enclosed copy of the Filing Receipt. Issuance of a corrected Filing Receipt is accordingly respectfully requested.

Applicants' undersigned attorney may be reached in our Costa Mesa,
California office at (714) 540-8700. All correspondence should continue to be directed to
our below-listed address.

Respectfully submitted,



Damond E. Vadnais
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CA_MAIN 117297v1



UNITED STATES PATENT AND TRADEMARK OFFICE

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APPL NO.	FILING OR 371 (c) DATE	ART UNIT	FIL FEE REC'D	ATTY. DOCKET NO	DRAWINGS	TOT CLMS	IND CLMS
10/530,189	02/03/2006	2812	1030	03500.017636	3	2	1

05514
FITZPATRICK CELLA HARPER & SCINTO
30 ROCKEFELLER PLAZA
NEW YORK, NY 10112

DEV

CONFIRMATION NO. 9636

FILING RECEIPT



OC000000018766679

Date Mailed: 05/15/2006

Receipt is acknowledged of this regular Patent Application. It will be considered in its order and you will be notified as to the results of the examination. Be sure to provide the U.S. APPLICATION NUMBER, FILING DATE, NAME OF APPLICANT, and TITLE OF INVENTION when inquiring about this application. Fees transmitted by check or draft are subject to collection. Please verify the accuracy of the data presented on this receipt. **If an error is noted on this Filing Receipt, please mail to the Commissioner for Patents P.O. Box 1450 Alexandria Va 22313-1450. Please provide a copy of this Filing Receipt with the changes noted thereon. If you received a "Notice to File Missing Parts" for this application, please submit any corrections to this Filing Receipt with your reply to the Notice. When the USPTO processes the reply to the Notice, the USPTO will generate another Filing Receipt incorporating the requested corrections (if appropriate).**

Applicant(s)

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Assignment For Published Patent Application

Canon Kabushiki Kaisha, Tokyo, JAPAN

Power of Attorney: The patent practitioners associated with Customer Number 05514.

Domestic Priority data as claimed by applicant

This application is a 371 of PCT/JP03/13074 10/10/2003

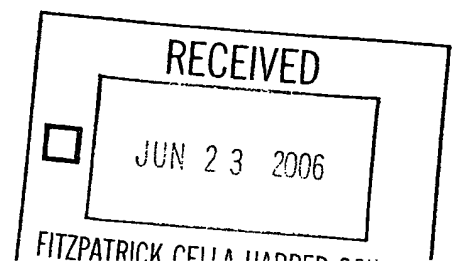
Foreign Applications

JAPAN NO. 2002-302286 10/16/2002

Acceptable Request to Retrieve Priority Application Received?

NO

Projected Publication Date: 08/17/2006



Non-Publication Request: No

Early Publication Request: No

Title

Polycrystalline ^{silicon}~~silicon~~ substrate

Preliminary Class

438

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Since the rights granted by a U.S. patent extend only throughout the territory of the United States and have no effect in a foreign country, an inventor who wishes patent protection in another country must apply for a patent in a specific country or in regional patent offices. Applicants may wish to consider the filing of an international application under the Patent Cooperation Treaty (PCT). An international (PCT) application generally has the same effect as a regular national patent application in each PCT-member country. The PCT process **simplifies** the filing of patent applications on the same invention in member countries, but **does not result** in a grant of "an international patent" and does not eliminate the need of applicants to file additional documents and fees in countries where patent protection is desired.

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